01/11/2006

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

Homogeneous Copper Interconnects for BEOL

Application Number:

Confirmation Number:

First Named Applicant:

Kevin Petrarca

Attorney Docket Number:

FIS920040258US1

Art Unit:

Examiner:

Search string:

(6709562 or 6380628 or 6339258 or 6337151 or 6743719 or 6472023 or 6680514

or 6071814 or 6136707 or 6174799 or 6368961 or 6726535 or 20040021226 or

20020027082).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass	
THN	1	6709562	2004-03-23	ANDRICACOS, ET AL.				
THV	2	6380628	2002-04-30	MILLER, ET AL.				
THN	3	6339258	2002-01-15	COONEY, III, ET AL.				
TH	4	6337151	2002-01-08	UZOH, ET AL.				
747	5	6743719	2004-06-01	CHEN, ET AL.				
THN	6	6472023	2002-10-29	WU, ET AL.				
HN	7	6680514	2004-01-20	GEFFKEN, ET AL.				
THI	8	6071814	2000-06-06	JANG				
THN	9	6136707	2000-10-24	COHEN				
THN	10	6174799	2001-01-16	LOPATIN, ET AL.				
rith	11	6368961	2002-04-09	LOPATIN, ET AL.				
142	12	6726535	2004-04-27	SHIH, ET AL.				

US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

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09/13/06

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

HOMOGENEOUS COPPER INTERCONNECTS FOR BEOL

Application Number:

10/711700

Confirmation Number:

5699

First Named Applicant:

Kevin Petrarca

Attorney Docket Number:

FIS920040258US1

Art Unit:

2811

Examiner:

Search string:

(5969422 or 6350688).pn

<u>Certification:</u> This Information Disclosure Statement was submitted under the following conditions, which satisfies the requirement under 37 CFR 1.97(e). The filer certified:

That no item of information contained in the information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application, and, to the knowledge of the person signing the certification after making reasonable inquiry, no item of information contained in the information disclosure statement was known to any individual designated in 37 CFR 1.56(c) more than three months prior to the filing of the information disclosure statement.

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
THN	1	5969422	1999-10-19	TING, ET AL.			
THN	2	6350688	2002-02-26	LIU, ET AL.			

Signature

Examiner Name	Date		
Seam la 27/26	09/13/2006		

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	Docket Number (Optional) FIS920040258US1	Application Number 10/711,700
DE OFFICE CITATION O (Officerel sheets if necessary)	Applicant(s) Kevin Petrarca, et al.	
APR 17 1006	Filing Date 09/30/04	Group Art Unit 2818
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18	3/			HE DA	TENT DOCUMENTS	
ATTENT & TRAC	Exempleor	Cito	Document Number Number-Kind Code ² (# (mount)	Publication Data	Name of Patentee or	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
	initials*			01/1996	GOLDBERG	
		AA"	100-0,70-1,010	07/2001	LANDAU	
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Exeminer Initials	Examiner City Foreign Paterd Document		Publication Date NAA-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Pessages or Relevant Figures Appeal	
		EP-0952242	11-16-1998	LANDAU, et al.	n - n to conference and B	<u>ئىن</u> س

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		NON PATENT LITERATURE DOCUMENTS NON PATENT LITERATURE DOCUMENTS Include name of the author (in CAPITAL LETTERS), title of the sricce (when appropriate), title of the item (book, include name of the author, etc.), date, page(s), volume-lasue number(s), publisher, city	┰╸
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1417	CA**	A Novel Electrolyte Composition for Copper Ptaling in Water Metallization, Electrochemical Processing in ULSI Fabrication and Semiconductor/Metal Deposition II: Proceedings of the Intenational Symposium; P.C.: Uziel LANDAU, et al., The Electrochemical Society, Inc.	
MN	CB**	Proceedings Volume 99-9. A Model of Superfilling in Damascene Electroplating, H. DELIGIANNI, et al.; The 195 th Meeting of Electrochemical Society, Inc. Meeting Abstracts, Volume 99-1 (May 2-6, 1999).	Ļ
HN	cc*	Model of Water Trickness Undomity Wall Location 100 4 (May 2-6, 1999).	
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HN	CE**	Proceedings Volume 99-9. Uziel LANDAU, A Novel Electrolyte Composition for Copper Plating in Water Metallization,	1
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	co	Volume 99-9.	

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astertal (**) next to the Cite No. are not suppose to care application for an earlier filting date under 35 U.S.C. 120.	2	11	Date Considered	07/06/06	
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